EAST Search History

EAST Search History (Prior Art)

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	4377	(room adj temperature) near5 (ambient adj temperature)	US-PGPUB; USPAT	OR	ON	2009/12/26 16:21
L2	4788	(room adj temperature) near5 (ambient adj temperature)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/12/26 16:22
L3	0	(room adj temperature) near3 (ambient adj temperature)with (lithography)	US-PGPUB; USPAT	OR	ON	2009/12/26 16:23
L4	1	(room adj temperature) near3 (ambient adj temperature) same (lithography)	US-PGPUB; USPAT	OR	ON	2009/12/26 16:24
L5	2	(room adj temperature) near3 (ambient adj temperature) same (lithograph$ or photolithograph$)	US-PGPUB; USPAT	OR	ON	2009/12/26 16:24
L6	0	(oxidation or oxidizing or oxidized or oxidize) near10 (carbon) near5 (deposit or residue or film or contaminant or impurity or particle or particulate) with ((room or ambient) adj4 temperature) same (lithograph$ or photolithograph$)	US-PGPUB; USPAT	OR	ON	2009/12/26 17:11

L7	0	(oxidation or oxidizing or oxidized or oxidize) near10 (carbon) near5 (deposit or residue or film or contaminant or impurity or particle or particulate or contamination) with ((room or ambient) adj4 temperature) same (lithograph$ or photolithograph$)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/12/26 17:12
L8	0	(oxidation or oxidizing or oxidized or oxidize) near10 (carbon) with ((room or ambient) adj4 temperature) same (lithograph$ or photolithograph$)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/12/26 17:12
L9	7	(oxidation or oxidizing or oxidized or oxidize) near10 (carbon) with (temperature) same (lithograph$ or photolithograph$)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/12/26 17:12
L10	233	(oxidation or oxidizing or oxidized or oxidize) near10 (carbon) with (temperature) and (lithograph$ or photolithograph$)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/12/26 17:13
L11	195	l10 and (wafer or semiconductor or silicon)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/12/26 17:14
L12	18	(oxidation or oxidizing or oxidized or oxidize) near10 (carbon) with ((room or ambient) near5 temperature) and (lithograph$ or photolithograph$)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/12/26 17:16
L13	19	(oxidation or oxidizing or oxidized or oxidize or oxidant) near10 (carbon$6) with ((room or ambient) near5 temperature) and (lithograph$ or photolithograph$)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/12/26 17:21

L14	19	(oxidation or oxidizing or oxidized or oxidize or oxidant) near10 (carbon or carbonaceous) with ((room or ambient) near5 temperature) and (lithograph$ or photolithograph$)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/12/26 17:21
L15	8	(oxidation or oxidizing or oxidized or oxidize or oxidant) near10 (carbon or carbonaceous or carbon adj gas or carbon adj monoxide or carbon adj dioxide or "CO" or "CO.sub.2" or "CO2") with (temperature or centigrade or celcius) same (lithograph$ or photolithograph$)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/12/26 17:33
L16	18994	(oxidation or oxidizing or oxidized or oxidize or oxidant) near10 (carbon or carbonaceous or carbon adj gas or carbon adj monoxide or carbon adj dioxide or "CO" or "CO.sub.2" or "CO2") with (temperature or centigrade or celcius)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/12/26 17:35
L17	9547	(oxidation or oxidizing or oxidized or oxidize or oxidant) near10 (carbon adj gas or carbon adj monoxide or carbon adj dioxide or "CO" or "CO.sub.2" or "CO2") with (temperature or centigrade or celcius)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/12/26 17:35
L18	147	l7 and (lithograph$ or photolithograph$)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/12/26 17:35

L19	129	l18 and (wafer or semiconductor or silicon or mask)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/12/26 17:36
L20	7239	(oxidation or oxidizing or oxidized or oxidize or oxidant) near5 (carbon adj gas or carbon adj monoxide or carbon adj dioxide or "CO" or "CO.sub.2" or "CO2") with (temperature or centigrade or celcius)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/12/26 17:38
L21	106	l20 and (lithograph$ or photolithograph$)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/12/26 17:39
L22	652	("CO") near5 (oxidize or oxidation or oxidizing or oxidized) with (low) near4 (temperature)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/12/26 17:42
L23	26	l22 and (lithograph$ or photolithograph$)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/12/26 17:42
L24	740	(carbon adj dioxide or carbon adj monoxide or "CO.sub.2" or "CO2") near5 (oxidize or oxidation or oxidizing or oxidized) with (low) near4 (temperature)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/12/26 17:44
L25	26	l23 and (lithograph$ or photolithograph$)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/12/26 17:44

L26	285	(carbon adj dioxide or carbon adj monoxide or "CO.sub.2" or "CO2") near5 (oxidize or oxidation or oxidizing or oxidized) with ((ambient or room) near4 (temperature) or "25 adj C")	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/12/26 17:51
L27	174	(carbon adj dioxide or carbon adj monoxide or "CO.sub.2" or "CO2") near5 (oxidize or oxidation or oxidizing or oxidized) near4 ((ambient or room) near4 (temperature) or "25 adj C")	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/12/26 17:51
L28	225	(carbon adj dioxide or carbon adj monoxide or "CO.sub.2" or "CO2") near5 (oxidize or oxidation or oxidizing or oxidized) near10 ((ambient or room) near4 (temperature) or "25 adj C")	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/12/26 17:52
L29	3	l28 and (lithograph$ or photolithograph$)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/12/26 17:52

EAST Search History (Interference)

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12/26/2009 5:55:24 PM